

Chiral magnetoresistance in Pt/Co/Pt zigzag wires

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The Rashba effect leads to a chiral precession of the spins of moving electrons, while the Dzyaloshinskii-Moriya interaction (DMI) generates preference towards a chiral profile of local spins. We predict that the exchange interaction between these two spin systems results in a “chiral” magnetoresistance depending on the chirality of the local spin texture. We observe this magnetoresistance by measuring the domain wall (DW) resistance in a uniquely designed Pt/Co/Pt zigzag wire and by changing the chirality of the DW with applying an in-plane magnetic field. A chirality-dependent DW resistance is found, and a quantitative analysis shows a good agreement with a theory based on the Rashba model. Moreover, the DW resistance measurement allows us to independently determine the strength of the Rashba effect and the DMI simultaneously, and the result implies a possible correlation between the Rashba effect, the DMI, and the symmetric Heisenberg exchange. *Published by AIP Publishing.* [<http://dx.doi.org/10.1063/1.4979031>]

In a magnetic system with inversion symmetry breaking combined with spin-orbit coupling (SOC), a variety of chirality-related phenomena occur. For instance, due to the Rashba effect,¹ the spins of the conduction electrons flowing at an interface are subject to an effective in-plane magnetic field due to the relativistic SOC, resulting in spin precession around the field during its transport. In this case, the direction of the magnetic field depends on the electron flow direction. In contrast, the precession of the conduction spins, as can be seen by comparing Figs. 1(a) and 1(b), is independent of the flow direction and shares the same rotational sense (denoted by a chirality of electrons, C_e).² Apart from the chiral behavior of the conduction spins, the chiral nature of localized spins has recently been discovered in ferromagnetic materials with inversion asymmetry and SOC. This gives rise to the Dzyaloshinskii-Moriya interaction (DMI),^{3,4} leading to a chiral spin texture of the localized spins (C_m), manifested as Néel type magnetic domain walls (DWs)⁵ and magnetic skyrmions,⁶ which are crucial to the future design of spintronic devices.

Although these two effects originate in different spin systems, one can speculate about their interplay through the exchange interaction between the conduction and localized spins.^{7–9} This results in a magnetoresistance (MR) which arises when the conduction electron spins propagate with a fixed chirality due to Rashba-type SOC and interact with the chiral DMI-induced magnetic texture. As shown in Figs. 1(c) and 1(d), this should lead to lower (higher) resistance when C_e is identical (opposite) to C_m . This MR can be termed as

“chiral MR” since the magnitude of the MR varies for spin textures with different chiralities. However, direct experimental evidence of this chiral MR is not found so far. Therefore, the measurement of chiral MR could not only enrich the spectrum of chirality-related physical phenomena but also shed light on the debated roles of the DMI and Rashba effect for fast current-driven DW motion¹⁰ and other SOC-related phenomena.^{11,12} Besides, this type of magnetoresistance provides further insights into engineering magnetic thin film systems with specifically desired chiral entities for future applications in nanoelectronics.

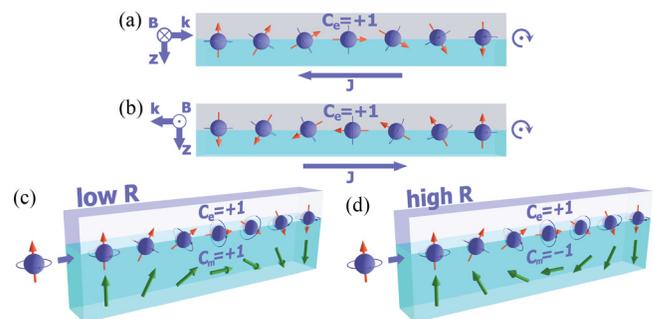


FIG. 1. (a) and (b) Spin configurations of electrons traveling in opposite directions ($k > 0$ or $k < 0$) in the presence of a Rashba field B at an interface (z is interface normal). The chirality of the profile of the spin precession is identical ($C_e = +1$) for both signs of k . (c) and (d) Inside a chiral magnetic texture with chirality C_m (green arrows), the rotation of electron spins generally follows the local spins due to the exchange interaction, while the finite degree of misalignment is inevitable, which gives rise to the DW resistance. The resistance is lower (higher) when the misalignment is suppressed (enhanced) by the Rashba effect. Please note that the misalignment is very much exaggerated in (d) for better legibility.

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In this work, a chiral MR is observed by measuring the magnetic DW resistance, which probes the interaction between an electric current and a magnetic DW. The magnetic DW is a twisted spin structure whose chirality can be altered by an external field,¹³ making it a perfect playground for measuring the chiral MR. We report results on a controllable, specifically designed DW system where chiral DWs are created by modifying the perpendicular magnetic anisotropy of a zigzag wire using a focused ion beam and applying an in-plane field for switching between the DW chiralities. It is found that the DW resistance varies with the chirality of DWs, and the observed behavior can be described by a theoretical model based on the Rashba Hamiltonian, lending strong support to our interpretation of a chirality-dependent interaction between the conduction and localized spins.

We first analytically derive the chiral MR explained in Fig. 1. For better legibility, we exaggerate the effect of Rashba SOC but mostly ignore the effect of the exchange interaction between the conduction electrons and local magnetization. However, in real systems, the exchange interaction is much higher than the Rashba interaction. Thus, we adopt this regime and start from the Rashba Hamiltonian ($\hbar^2 k_R/2m_e$) $\boldsymbol{\sigma} \cdot (\mathbf{k} \times \hat{\mathbf{z}})$ added to a strong exchange interaction $J\boldsymbol{\sigma} \cdot \mathbf{m}$. Here, k_R characterizes the preferred spin precession rate, \hbar the Planck constant, m_e the electron mass, \mathbf{k} the electron momentum, $\hat{\mathbf{z}}$ the interface normal, and $\boldsymbol{\sigma}$ the spin Pauli matrix, J the exchange energy, and \mathbf{m} the direction of magnetization. The Rashba model captures core effects of the strong SOC combined with inversion symmetry breaking at the interface.¹⁴ Recently, it was predicted⁸ that linear effects of the chirality can be obtained from non-chiral theories simply by replacing $\partial_x \mathbf{m}$, where x is the current flow direction, with the so-called chiral derivative $\tilde{\partial}_x \mathbf{m} = \partial_x \mathbf{m} + k_R(\hat{\mathbf{z}} \times \hat{\mathbf{x}}) \times \mathbf{m}$. Here, we apply the chiral derivative to the DW resistance derived by Levy and Zhang,¹⁵ $R_{LZ} = \rho_{DW} \int (\partial_x \mathbf{m})^2 dx$, where ρ_{DW} is the DW resistivity. By assuming a DW with the Walker profile¹⁶ and after some algebra (see [supplementary material](#)), we obtain $\tilde{R}_{LZ} = 2\rho_{DW}(\lambda^{-1} \pm k_R \pi \sin \phi)$, where λ is the DW width, ϕ the DW in-plane angle, and \mp refers to up-down and down-up DWs, respectively. The DW is a Bloch wall when $\phi = 0$ and a Néel wall when $\phi = \pm\pi/2$. The second term in \tilde{R}_{LZ} is the chiral DW resistance, which changes its sign when the DW chirality changes.

Apart from the contribution from the inhomogeneity of the magnetic texture, the resistance also depends on the local magnetization direction itself due to anisotropic magnetoresistance (AMR).¹¹ Based on AMR, the resistance is lower (higher) where the magnetization direction is perpendicular (parallel) to the current flowing direction. The theory of AMR implies that the MR is proportional to $\sin^2 \phi$. After adding the AMR contribution to \tilde{R}_{LZ} , the total DW resistance can be written as

$$R_{DW\pm} = \Delta R_{AMR} \sin^2 \phi + 2\rho_{DW} \lambda^{-1} \pm R_{chiral} \sin \phi, \quad (1)$$

where ΔR_{AMR} is a proportionality constant of AMR and $R_{chiral} = 2\rho_{DW} k_R \pi$ is the chiral DW resistance.

Experimentally, ϕ can be tuned by applying an in-plane field H_x which is perpendicular to the DW. To determine the

relation between ϕ and H_x , we start from the energy functional $E = \int [A(\partial_x \mathbf{m})^2 + \mu_0 H_k M_S (1 - m_z^2) + \mu_0 H_d M_S m_x^2 + D \hat{\mathbf{y}} \cdot (\mathbf{m} \times \partial_x \mathbf{m}) - \mu_0 H_x M_S m_x] dx$,¹⁷ where A is the exchange stiffness, H_k the perpendicular anisotropy, H_d the demagnetizing field, D the DMI parameter, and M_S the saturation magnetization. Applying the Walker ansatz reduces the energy minimizing condition $\partial E/\partial \phi = 0$ gives

$$\sin \phi = \frac{\pi \pm D + \mu_0 H_x M_S \lambda}{2 \mu_0 H_d M_S \lambda}. \quad (2)$$

Here, we ignore the dependence of λ on H_x , which is too weak to affect the analysis (see [supplementary material](#)). By substituting Eq. (2) into Eq. (1), we plot in Fig. 2 the resulting R_{DW}/R_{min} as a function of H_x/H_{min} , where R_{min} and H_{min} are the values where the DW resistance is minimal. Three observations can be made: (i) There is an increase in the resistance when H_x increases. This is expected since the field pulls the DW into a Néel state, thereby increasing the AMR. (ii) For a finite DMI, the DW is in between the Bloch type and the Néel type for $H_x = 0$, i.e., $0 < \phi < \pi/2$.^{18,19} This tilt angle depends on the magnitude of the DMI, allowing us to determine the DMI energy density $D = \mu_0 H_{DMI} M_S \lambda$, where H_{DMI} is the effective DMI field, by measuring the field shift H_{min} (see [supplementary material](#)). (iii) The most striking feature from this theory is a difference in R_{DW} (indicated by $2R_{chiral}$ in Fig. 2) at high applied in-plane fields, showing the unique dependence of the DW resistance on chirality. It is therefore very useful to measure the in-plane field dependence of DW resistance since it allows us to independently determine the strength of DMI and the Rashba effect simultaneously (see [supplementary material](#)).

To possibly measure R_{chiral} , one could naively use a straight Pt/Co/Pt nanowire as reported earlier,²⁰ see Fig. 3(a). Here, the red part indicates the region irradiated by Ga ions which reduce the perpendicular magnetic anisotropy and allow the nucleation of DWs on two sides.²¹ However, this straight wire is not suitable for measuring the chiral resistance, as we will experimentally show later on, because the DW pair has an opposite chirality when applying a high in-plane field. Thus, the total chiral resistance $R_{DW+} + R_{DW-}$ is averaged out, as shown in the inset of Fig. 2. In order to

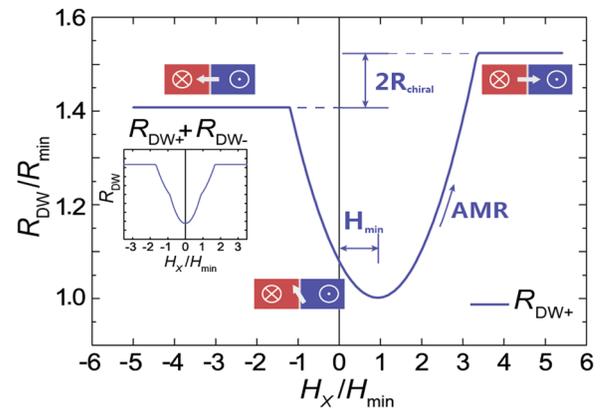


FIG. 2. Theoretical prediction of R_{DW+}/R_{min} , where R_{min} is the resistance at H_{min} , as a function of in-plane field H_x . The white arrows indicate the DW angle. Inset: The total DW resistance for two DWs with opposite chiralities.

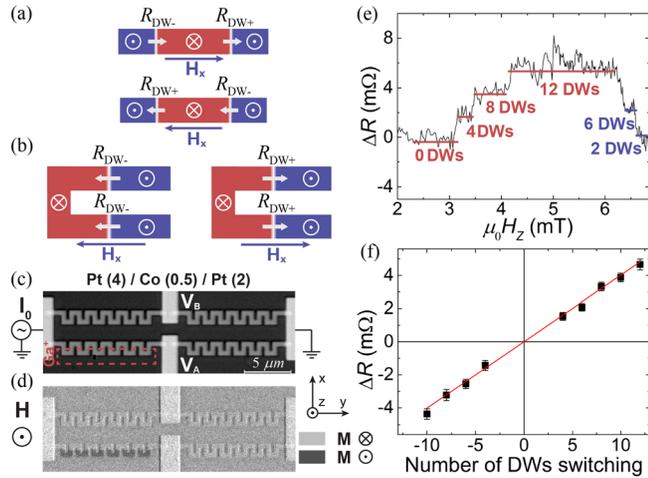


FIG. 3. (a) and (b) A straight (zigzag) magnetic wire where two DWs with opposite (same) chiralities are created. (c) Kerr microscopy image of 4 Pt/Co/Pt strips in a Wheatstone bridge configuration, where one of the strips has been patterned using a focused Ga ion beam. (d) Kerr microscopy image upon applying a perpendicular magnetic field, showing the nucleation of DWs. (e) Resistance change in the wire as a function of perpendicular field. (f) Magnitude of resistance change as a function of the number of DWs nucleating (+) or annihilating (-). The error bars are single standard deviations. The red solid line is a linear fit.

overcome this difficulty, we develop an alternative, zigzag strip [Fig. 3(b)]. The zigzag together with anisotropy modifications allows for two DWs with the same chirality where C_m is controllable by the in-plane field.

Figures 3(c) and 3(d) show Kerr microscopy images of the sample structure used for the chiral DW resistance measurements. A perpendicularly magnetized stack Pt(4 nm)/Co(0.5 nm)/Pt(2 nm) is employed to provide a sizable DMI.²² Here, the red dashed area indicates the Ga⁺ irradiation region with a dose of $0.5 \times 10^{13} \text{ cm}^{-2}$ at 30 keV. Four 1 μm wide zigzag wires are patterned by electron-beam lithography and a lift-off, in the form of a Wheatstone bridge to improve the signal-to-noise ratio. We apply an AC current with a constant strength $I_{\text{RMS}} = 0.25 \text{ mA}$ at a frequency of $f = 501 \text{ Hz}$ and measure the differential output signal $V_{\text{diff}} = V_A - V_B$ with a lock-in amplifier [See Fig. 3(c) for V_A and V_B], which can be used to calculate the change of the resistance in the wire due to the DWs.

Figure 3(e) shows the resistance change ΔR in the wire for DWs whose number is controllable. In the measurement, the magnetization is first saturated by applying $\mu_0 H_z = -10 \text{ mT}$, and then a positive magnetic field is swept from 0 mT to 10 mT. A stepwise increase in ΔR is observed, corresponding to the appearance of DWs. The coercive fields of the irradiated domains show small statistical variations so that not all DWs appear simultaneously. The number of DWs nucleated can easily be determined by Kerr microscopy (see [supplementary material](#)). The solid red and blue lines indicate ranges where the number of DWs is constant, and successive increases (decreases) in DWs are indicated by red (blue). In Fig. 3(f), ΔR is plotted as a function of the number of DWs present, showing a linear dependence as expected. From the linear fit, we extract a resistance change of $0.38 \pm 0.02 \text{ m}\Omega$ per DW, which is comparable to our previous report.²⁰

The procedure to measure the chiral DW resistance is as follows: (i) The field H_x at which we want to measure R_{DW} is set, (ii) we saturate the sample at $\mu_0 H_z = -10 \text{ mT}$, (iii) a field of $\mu_0 H_z = +1 \text{ mT}$ is applied and V'_{diff} is measured using a lock-in amplifier, (iv) we carefully increase $\mu_0 H_z$ to nucleate a few domains, and (v) $\mu_0 H_z$ is then reduced back to $\mu_0 H_z = +1 \text{ mT}$ and V''_{diff} is measured, and the voltage difference $\Delta V = V''_{\text{diff}} - V'_{\text{diff}}$ is recorded. Steps (iii)–(v) are then repeated to systematically track the resistance change as a function of the number of DWs giving an accurate measure of R_{DW} at a given H_x . This procedure is then repeated for every H_x . In order to quantitatively compare the measured R_{DW} as a function of H_x with the theoretical model, we should consider the DW resistance in the magnetic Co layer, which can be obtained from ΔR by using a Fuchs-Sondheimer model²¹ to exclude current shunting through the Pt layers.

The measured R_{DW} of the Pt/Co/Pt zigzag and straight wires as a function of in-plane field are shown in Figs. 4(a) and 4(b), respectively. The blue and red squares represent the magnetic switching with different polarities (up-down and down-up). For the zigzag wire, we observe that R_{DW} rises as H_x increases, owing to an increase in AMR when a Bloch wall transforms into a Néel wall. In addition, we clearly observe a field shift, which originates mainly from the DMI^{18,19,22} and partially from the chiral MR (see [supplementary material](#)). As expected from the chirality of the DW spin structures, the field shift has an opposite sign for DWs of opposite polarity. Another prominent observation in Fig. 4(a) is that the magnitude of the DW resistance depends on the chirality of Néel walls, which can be varied by reversing the in-plane field or changing the polarity of the Néel walls. As can be seen, a substantial difference in resistance at saturation is observed in the zigzag wire, as expected from our theoretical prediction. Such a difference in resistance for opposite chirality of Néel walls is strongly supported by the results from the straight wire, where all chirality-induced effects should be canceled out due to the opposite chirality of two DWs under an in-plane field. Indeed, in contrast to the results from the zigzag wire, no significant differences between the up-down and down-up datasets are seen in Fig. 4(b). This is additionally confirmed by performing a fit to the data as further explained in the [supplementary material](#), showing a good agreement with the behavior illustrated in

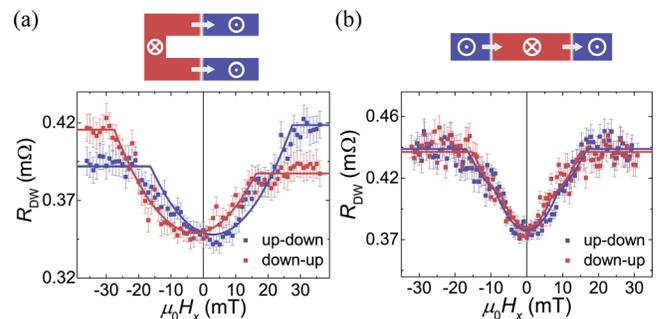


FIG. 4. The measured DW resistance of a single DW as a function of in-plane field on (a) a zigzag wire and (b) a straight wire. The blue and red squares represent the magnetic switching with different polarities (up-down and down-up, respectively). The blue and red solid lines are fits to the data based on the theoretical model. Error bars are single standard deviations.

the inset of Fig. 2. Consequently, we can conclude that the aforementioned resistance difference results from the chirality of DWs.

Next, we estimate the strength of the Rashba effect and DMI by fitting to our theoretical model [Eq. (1)]. We assume standard material parameters for Co as used in our previous works:^{18,23} $A = 16 \times 10^{-12}$ J/m, $M_S = 1070$ kA/m, effective anisotropy $K_{\text{eff}} = 0.28$ MJ/m³, and $\lambda = \sqrt{A/K_{\text{eff}}} = 8$ nm. The fits are plotted in Fig. 4(a) as blue and red lines, which is in a good agreement with the experimental data. Since we fit these two datasets separately, we extract the free parameters by taking the average of the up-down and down-up data: $\mu_0 H_d = 34.7$ mT, $\Delta R_{\text{AMR}} = 50$ m Ω , $\rho_{\text{DW}} = 1.41 \times 10^{-9}$ Ω m, $D = -0.049$ mJ/m², $\mu_0 H_{\text{DMI}} = D/\lambda M_S = -5.9$ mT, and $k_R = -1.43 \times 10^6$ m⁻¹ (the parameter errors are presented in the [supplementary material](#)). The AMR parameter is similar to the value $\Delta R_{\text{AMR}} = 86$ m Ω obtained from a micro-magnetic simulation^{24,25} (see [supplementary material](#)), demonstrating that the increase in DW resistance at a small field is indeed due to AMR. The estimated D is comparable to the previously reported value $D = 0.1$ mJ/m² as measured in a similar Pt/Co/Pt stack.¹¹ For the Rashba coefficient, a first-principles calculation predicts $k_R = 14.9 \times 10^6$ m⁻¹ for a Pt/Co interface. This value is not representative for our experimental system since a Pt/Co/Pt stack is used where two opposing Pt/Co and Co/Pt interfaces need to be taken into account, leading to a much smaller effective Rashba coefficient.^{8,26,27} Indeed, we extract a k_R which only amounts up to 9.6% of the quoted theoretical value.

Since we can independently measure the strength of the Rashba effect and DMI, sharing common origins (SOC and structural inversion asymmetry) in the same system, we can explore their correlation possibly shedding light on their entangled role in SOC-related phenomena.^{11,12} For example, it is shown that the Rashba model implies that the interfacial DMI energy density D is proportional to a Rashba coefficient in a form of⁸

$$D = 2k_R A. \quad (3)$$

Using the values obtained from our fitting, we find $A = D/2k_R = 17 \times 10^{-12}$ J/m, which is of the same order of magnitude as the exchange stiffness of bulk Co.²³ Systematic errors of D and k_R could arise from the uncertainty in K_{eff} and λ due to the Ga irradiation, which we do not separately address in the current work. However, since D and k_R both scales with λ , the errors do not affect the verification of Eq. (3). This agreement found from the Rashba model and using our experimentally extracted parameters implies that the DMI in our sample may originate from the Rashba-induced twisted Ruderman-Kittel-Kasuya-Yosida interaction^{8,9,28,29} rather than the original explanation by Moriya⁴ based on a superexchange model. Quantitatively, the Rashba strength is proportional to the ratio of symmetric and antisymmetric exchange. It implies that the DMI may be tuned by controlling the strength of the Rashba effect (e.g., by applying an electric field^{30,31}) or the strength of the symmetric exchange. In passing, we note that a one-to-one correspondence between the DMI and symmetric exchange was demonstrated very recently by optical spin-wave spectroscopy.³²

Although we used the Rashba model to analyze the chiral DW resistance in view of chiral precession of conduction electron spins, another possible explanation might be found in considering the bulk spin Hall effect (SHE) of Pt. As far as symmetry constraints are concerned, it is not impossible for the SHE to generate the chiral DW resistance, although such a theory is not developed yet. Specifically, considering that the SHE is of bulk origin, we do not understand how the chiral DW resistance due to the SHE could match with the DMI, which, in our system, is of interfacial origin. In contrast, the good match between $R_{\text{chiral}}/R_{\text{LZ}}$ and $(\pi\lambda/2)(D/A)$ in our experiment suggests that the chiral DW resistance and the DMI share the common origin.

In summary, we measured the DW resistance on a magnetic zigzag wire and found that it was chirality dependent. This measurement allows us to unambiguously determine the magnitude of the Rashba effect and DMI as independent parameters. A quantitative agreement was found between the experiment and theory, supporting the idea that the Rashba effect could be coupled to DMI via the symmetric exchange interaction. Besides its fundamental importance, the chiral DW resistance opens up possibilities of designing energy-efficient magnetic DW devices, for example, if we combine it with the recently proposed electric-field control of DW chirality.³³

See [supplementary material](#) for the (1) derivation of chiral DW resistance, (2) DW width variation, (3) quantification of the DMI by the field shift, (4) the real-time DW resistance measurement, (5) determination of the anisotropic magnetoresistance, (6) straight Pt/Co/Pt wire: fitting the experimental data, (7) DW resistance measurement of other samples, and (8) DW resistance measurement of Pt/Co/AlOx.

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